








	NEW ! 	NEW ! 			Selection and production of the most efficient and performing polishing cloths for metallography and industrial polishing.
X710 X715	X620	X550	X540	X500	
High density polishing pad, for high and plan stock removal. For hard and very hard materials. (X715: perforated) 30, 15, 9 or 6μ	Non-woven polishing cloth, for plan polishing. Internal film barrier. Medium, hard and very hard materials. 15, 9, 6 or 3μ	Woven satin polishing cloth with internal barrier film. Excellent flatness and durability. Higher material removal. All materials. 15, 9, 6 or 3μ	Woven silk polishing cloth with internal barrier film and PVC foil. Good flatness. All materials. 9, 6, 3 or 1μ	Woven silk polishing cloth with internal barrier and thin adhesive film. Excellent flatness and semifinishing. All materials. 9, 6, 3 or 1μ	
	NEW ! 		NEW ! 	NEW ! 	
X300	X240	X220	X200	X100	
100% pure woven wool polishing cloth. Medium and soft materials. Semi-finishing or finishing with 3μ. 6 or 3μ	Soft flocked polishing cloth with internal barrier film. Flatness, durability and finishing. Semi-finishing and finishing of all materials. 9, 6, 3 or 1μ	Soft flocked polishing cloth. Flatness and finishing. Semi-finishing and finishing of all materials. 6, 3 or 1μ	Very soft flocked polishing cloth. Semi-finishing and finishing of all materials, with diamond or fine Alumina. 3, 1 or 1/4μ	Buffed polyurethane. Super-finishing on many materials. To use with Colloidal Silica (XA05) or extra-fine Alumina. 1 to 0,04μ	
Our adhesive polishing cloths X series are also available in a MAGNETIC version, M series, and compatible on electrostatic pads.					